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The measurement of temperature using diodes is based on the observation that the voltage across the forward-biased diode increases with decrease in temperature<sup>[1-10]</sup>. The forward characteristic of GaAlAs diode can be understood in terms of transport in high electric field which exists at a semiconductor junction<sup>[11]</sup>. This is also the basic aspect of quantum Hall effect<sup>[12]</sup>. The bend at low temperature can be associated with the characteristic of 'bulk' GaAs in GaAlAs diode<sup>[13]</sup>. Below about 50 K, the forward voltage increases more rapidly as the temperature is reduced., which gives rise to a bend in the temperature dependence of forward voltage. The diodes are generally operated with 10 µA of forward current. These diodes have been used in the temperature range 1.4 to 450 K with an accuracy of 50 mK. A temperature sensitivity of a few mV/K has been obtained at high temperatures (T>50 K). In the low temperature range (T<50 K), the sensitivity exceeds 100 mV/K. There have been several studies, such as linearity, stability, power dissipation, noise and effect of  $\gamma$ -radiation, of semiconductor diodes in the context of temperature measurement.

The forward characteristics of silicon diode temperature sensors are strongly magnetic field dependent, which limits their application in magnetic fields; although they

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# Calibration of GaAlAs semiconductor diode for temperatures between 10-300 K

Abstract

The forward voltage of GaAlAs semiconductor diode has been measured for temperatures between 10-300 K and for current values between 10 nA and 450  $\mu$ A. The forward voltage as a function of temperature is least-squares fitted in two temperature ranges 10-22 K and 50-300 K. The coefficients are given for 2<sup>nd</sup> order polynomials.

Key Words

Semiconductor; Temperature sensors; GaAlAs.

have been used under magnetic field of 0.1 T. The problem of magnetic field dependence of the forward characteristic was overcome with the GaAlAs diode, which is a direct band gap semiconductor. Moreover, the low temperature sensitivity of GaAlAs diode with 10 µA of sensing current has been found to be several times higher than that of Silicon diods. Earlier, we have studied the GaAlAs semiconductor diode for current values between 10 nA and 450  $\mu$ A, for ultra low temperature application. It was observed that GaAlAs semiconductor diode can be used in the ultra low temperature range (~mK) by reducing the current by several orders of magnitude. Semiconductor diodes have also been studied in other contexts. Some of these studies are: carrier transport in a GaAs p-n junction using light modulated scanning tunneling spectroscopy<sup>[14]</sup> and determination of the ideality parameter<sup>[15]</sup>. In certain possible applications of semiconductor diodes for temperature measurement, a high precision in the measurement of temperature is needed. Such situations include, the measurement of temperature drift curve in low temperature heat pulse calorimetry<sup>[16,17]</sup>.

In this paper, we give the calibration of the temperature dependence of forward voltage of GaAlAs diode for various current values between 10 nA and 450  $\mu$ A and for two temperatures ranges 10-22 K and 50-300 K. The coefficients are given for 2<sup>nd</sup> order polynomials.

The measurements were carried out using a computer controlled four-probe setup built around a closed cycle refrigerator. The diode in the CU package configuration is epoxied into a flat cylindrical disk and the sensor leads are thermally anchored to the same disk. The metal encapsulation of the diode was fixed o the sample space of the closed cycle helium refrigerator with 0.2mm thick indium foil and a thin layer of Apiezon-N grease by clamping with an aluminum disk with screws using moderate pressure. The leads were further anchored at the sample space to minimize any thermo-electromotive force developed. The temperature of the sample site was controlled using a calibrated type-D silicon diode thermometer in conjunction with a Leybold model LTC60 temperature controller (Leybold AG, Germany). Measurements were carried out between 10 K - 50 K, for forward current from 10 nA to 450  $\mu$ A. The temperature increment was 2 K and the current increment was in 11 equal logarithmic steps. Each data point was obtained by averaging 50 reading. For temperatures between 50-300 K the temperature increment was 10 K and the current increment was in 11 equal logarithmic steps. A constant current was provided to the GaAlAs diode from a Keithley (Keithley Instruments, USA) model 224/2243 programmable current source. The forward voltage was measured using a Keithley model 182 sensitive digital voltmeter.

The forward current  $I_f$  is related to the forward voltage  $V_f$  in a GaAs p-n junction, as follows:

#### $I_f \approx \exp(qV_f/\eta kT)$

(1)

(2)

where q is the electronic charge, k is the Boltzmann constant, T is the temperature, and  $\eta$  is the ideality factor. Depending on the value of  $\eta$ , four operating regions have been defined: recombination, diffusion, high injection and series resistance regions. The Eq.1 gives rise to a linear temperature dependence of V, for a fixed value of current. However, for extended temperature range (~100 K), there is significant deviation of linearity. Therefore, the semiconductor diode are generally calibrated with respect to standard and interpolation data is made. However, in some situations a lower order polynomial covering a large temperature range is needed. The least-squares fitting provides such a polynomial. First the temperature is determined using the calibrated voltage value of the GaAlAs diode for 10 µA of current, which was provided by the manufacturer. The measured voltage as a function of temperature, for various current values, was then least-squares fitted to the following polynomials:

For the least squares fitting only 7 points were used for temperatures between 10-22 K. The 1<sup>st</sup> and 2<sup>nd</sup> order least squares fittings were of similar natures in terms of roots and sign of the coefficients for both the temperature ranges and for all current values. The R<sup>2</sup> of the least squares fitting was nearly 1.00. TABLE 1 gives the coefficients of 2<sup>nd</sup> order least squares fitting for temperatures around 15 K. The coefficients of 2<sup>nd</sup> order least squares fitting for temperatures between 50-300 K are given in TABLE 2<sup>[18]</sup>. The 2<sup>nd</sup> order least squares fitting has three coefficients a<sub>0</sub>. a<sub>1</sub> and a<sub>2</sub>. The coefficient a<sub>0</sub> represents the maximum forward voltage. The coefficient a<sub>1</sub> represents the sensitivity or the linearity and a<sub>2</sub> represents the deviation from linearity.

TABLE 1 : The  $2^{st}$  order least squares fitting of GaAlAs diode around 15 K

Current	$a_0$	a1	$a_2$	<b>R</b> <sup>2</sup>	T <sub>0</sub> (K)
10 nA	3.22296	-1.15293×10-1	1.93667×10-3	1.00	-
30 nA	3.59690	-1.31390×10-1	2.09518×10-3	1.00	-
100 nA	3.90296	-1.33979×10-1	1.83726×10-3	1.00	-
300 nA	4.22005	-1.38386×10-1	1.66679×10-3	1.00	-
1 μΑ	4.71798	-1.56223×10-1	1.82899×10-3	1.00	-
3 μΑ	5.20579	-1.71532×10-1	1.92919×10-3	1.00	-
10 μΑ	5.71791	-1.80132×10-1	1.78175×10-3	1.00	-
30 µA	6.41416	-2.08524×10-1	2.17747×10-3	1.00	-
100 μΑ	7.10746	-2.27733×10-1	2.30805×10-3	1.00	-
300 μΑ	7.85295	-2.50554×10-1	2.48469×10-3	1.00	-
450 μΑ	8.08877	-2.50916×10-1	2.23267×10-3	1.00	-

TABLE 2 : The  $2^{st}$  order least squares fitting of GaAlAs diode for temperatures between 50-300 K

Current	a <sub>0</sub>	a <sub>1</sub>	$a_2$	<b>R</b> <sup>2</sup>	T <sub>0</sub> (K)
10 nA	1.541	-2.496×10-3	-3.030×10-6	1.00	411.637
30 nA	1.543	-2.290×10-3	-3.057×10-6	1.00	428.549
100 nA	1.541	-2.014×10-3	-3.247×10-6	1.00	445.308
300 nA	1.535	-1.734×10-3	-3.488×10-6	1.00	459.896
1 μΑ	1.527	-1.416×10-3	-3.763×10-6	1.00	476.041
3 μΑ	1.519	-1.138×10-3	-3.961×10-6	1.00	492.070
10 μΑ	1.514	-8.977×10-4	-3.975×10-6	1.00	514.505
30 µA	1.519	-8.145×10-4	-3.601×10-6	1.00	546.084
100 μΑ	1.540	-9.455×10-4	-2.631×10-6	1.00	606.295
300 µA	1.581	-1.279×10-3	-1.302×10-6	0.99	715.318
450 μΑ	1.602	-1.450×10-3	-7.288×10-7	0.99	790.460

The calibration of the forward voltage of GaAlAs semiconductor diode is given which can be used to measure temperatures between 50 mK – 300 K. The forward voltage as a function of temperature is least-squares fitted in two temperature ranges 10-22 K and 50-300 K. The coefficients are given for  $2^{nd}$  order polynomials.

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